

Special Issue

CO₂ Capture and Utilization and Molecular Simulation

Message from the Guest Editors

This Special Issue, entitled "CO₂ Capture and Utilization and Molecular Simulation", aims to gather high-quality contributions that address the most recent and innovative advancements in CCU technology and molecular simulation-assisted CCU process development. Topics include, but are not limited to, the following:

- The development of models or simulations for CO₂ capture and utilization
- The innovative development of CO₂ capture and utilization technologies.
- Multiscale molecular simulation for the CO₂ capture process
- The process design, optimization and economic evaluation of an CO₂ capture system

Guest Editors

Dr. Ying-Chieh Hung

Prof. Dr. Chieh-Ming Hsieh

Dr. Ardila Hayu Tiwikrama

Deadline for manuscript submissions

closed (30 April 2025)



Processes

an Open Access Journal
by MDPI

Impact Factor 2.8
CiteScore 5.5



mdpi.com/si/185815

Processes
Editorial Office
MDPI, Grosspeteranlage 5
4052 Basel, Switzerland
Tel: +41 61 683 77 34
processes@mdpi.com

[mdpi.com/journal/
processes](https://mdpi.com/journal/processes)





Processes

an Open Access Journal
by MDPI

Impact Factor 2.8
CiteScore 5.5



[mdpi.com/journal/
processes](https://mdpi.com/journal/processes)



About the Journal

Message from the Editor-in-Chief

You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

Prof. Dr. Giancarlo Cravotto

Department of Drug Science and Technology, University of Turin, Via P. Giuria 9, 10125 Turin, Italy

Author Benefits

Open Access:

free for readers, with article processing charges (APC) paid by authors or their institutions.

High Visibility:

indexed within Scopus, SCIE (Web of Science), Ei Compendex, Inspec, AGRIS, and other databases.

Journal Rank:

CiteScore - Q2 (Chemical Engineering (miscellaneous))